

Substitute for form 1449A/PTO (modified) INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary) Page 2 of 5	Application Number	10/729073
	Filing Date	December 5, 2003
	First Named Inventor	DAMS, RUDOLF J.
	Art Unit	
	Examiner Name	
	Attorney Case Number	58809US002

U.S. Patent Documents					
Exam. Init.*	Cite No.	Document Number	Publication Date or Issue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Doc. Number-(Kind Code if Known)			
RS	A29	US- 4,536,298	8/20/85	Kamei et al.	
RS	A30	US- 4,647,413	3/3/87	Savu	
RS	A31	US- 4,668,408	5/28/87	Chang	
RS	A32	US- 4,687,707	07/18/87	Matsuo et al.	08/1987
RS	A33	US- 4,795,764	1/3/89	Alm et al.	
RS	A34	US- 4,923,720	5/8/90	Lee et al.	
RS	A35	US- 4,975,502	12/4/90	Morita et al.	
RS	A36	US- 4,983,769	1/8/91	Bertocchio et al.	
RS	A37	US- 5,022,713	6/11/91	Pugh et al.	
RS	A38	US- 5,027,742	7/2/91	Lee et al.	
RS	A39	US- 5,066,522	11/19/91	Cole et al.	
RS	A40	US- 5,085,786	2/4/92	Alm et al.	
RS	A41	US- 5,108,799	4/28/92	Hoy et al.	
RS	A42	US- 5,130,477	7/14/92	Koike et al.	
RS	A43	US- 5,211,342	5/18/93	Hoy et al.	
RS	A44	US- 5,274,159	12/28/93	Pellerite et al.	
RS	A45	US- 5,294,248	3/15/94	Chittofrati et al.	
RS	A46	US- 5,306,758	4/26/94	Pellerite	
RS	A47	US- 5,352,752	10/4/94	Koike et al.	
RS	A48	US- 5,424,438	6/13/95	Chittofrati et al.	
RS	A49	US- 5,698,138	12/16/97	Visca et al.	
RS	A50	US- 5,705,591	1/6/98	Matsuda et al.	
RS	A51	US- 5,739,369	4/14/98	Matsumura et al.	
RS	A52	US- 5,851,674	12/22/98	Pellerite et al.	
RS	A53	US- 5,863,612	1/26/99	DeSimone	
RS	A54	US- 5,910,557	6/8/99	Audenaert et al.	
RS	A55	US- 5,919,886	7/6/99	Matsuda et al.	
RS	A56	US- 5,922,787	7/13/99	Kondo et al.	

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*Examiner: /Rabon Sergeant/	Date Considered: 01/05/2007
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